

Sputtering Target for Semiconductor Industry Research Report 2023

https://marketpublishers.com/r/S64EC3E21BCCEN.html

Date: August 2023

Pages: 102

Price: US\$ 2,950.00 (Single User License)

ID: S64EC3E21BCCEN

Abstracts

The sputtering target material is the core of semiconductor wafer manufacturing, and the chip has very high requirements for sputtering target material, which requires high purity of target material, generally over 99.999%.

Highlights

The global Sputtering Target for Semiconductor market is projected to reach US\$ million by 2029 from an estimated US\$ million in 2022, at a CAGR of % during 2023 and 2029.

As for global Sputtering Target for Semiconductor market, there are several key players, like Materion (Heraeus), JX Nippon Mining & Metals Corporation, Praxair, Plansee SE, Hitachi Metals, Honeywell, TOSOH, Sumitomo Chemical, ULVAC, Ningbo Jiangfeng, Luvata, GRIKIN Advanced Material, Luoyang Sifon Electronic Materials, FURAYA Metals, Advantec, Fujian Acetron New Materials Co., Ltd, Umicore Thin Film Products, Angstrom Sciences, Changzhou Sujing Electronic Material, etc.

Asia-Pacific is the largest consumption region of Sputtering Target for Semiconductor, with a consumption market share nearly 52%. The second place is North America; following Asia-Pacific with the consumption market share over 23%.

Report Scope

This report aims to provide a comprehensive presentation of the global market for Sputtering Target for Semiconductor, with both quantitative and qualitative analysis, to help readers develop business/growth strategies, assess the market competitive



situation, analyze their position in the current marketplace, and make informed business decisions regarding Sputtering Target for Semiconductor.

The Sputtering Target for Semiconductor market size, estimations, and forecasts are provided in terms of output/shipments (Tons) and revenue (\$ millions), considering 2022 as the base year, with history and forecast data for the period from 2018 to 2029. This report segments the global Sputtering Target for Semiconductor market comprehensively. Regional market sizes, concerning products by types, by application, and by players, are also provided. The influence of COVID-19 and the Russia-Ukraine War were considered while estimating market sizes.

For a more in-depth understanding of the market, the report provides profiles of the competitive landscape, key competitors, and their respective market ranks. The report also discusses technological trends and new product developments.

The report will help the Sputtering Target for Semiconductor manufacturers, new entrants, and industry chain related companies in this market with information on the revenues, production, and average price for the overall market and the sub-segments across the different segments, by company, product type, application, and regions.

Key Companies & Market Share Insights

In this section, the readers will gain an understanding of the key players competing. This report has studied the key growth strategies, such as innovative trends and developments, intensification of product portfolio, mergers and acquisitions, collaborations, new product innovation, and geographical expansion, undertaken by these participants to maintain their presence. Apart from business strategies, the study includes current developments and key financials. The readers will also get access to the data related to global revenue, price, and sales by manufacturers for the period 2018-2023. This all-inclusive report will certainly serve the clients to stay updated and make effective decisions in their businesses. Some of the prominent players reviewed in the research report include:

Materion (Heraeus)

JX Nippon Mining & Metals Corporation

Praxair



	Plansee SE			
	Hitachi Metals			
	Honeywell			
	TOSOH			
	Sumitomo Chemical			
	ULVAC			
	Ningbo Jiangfeng			
	Luvata			
	GRIKIN Advanced Material			
	Luoyang Sifon Electronic Materials			
	FURAYA Metals			
	Advantec			
	Fujian Acetron New Materials Co., Ltd			
	Umicore Thin Film Products			
	Angstrom Sciences			
	Changzhou Sujing Electronic Material			
duc	ct Type Insights			

Produ

Global markets are presented by Sputtering Target for Semiconductor type, along with growth forecasts through 2029. Estimates on production and value are based on the price in the supply chain at which the Sputtering Target for Semiconductor are procured by the manufacturers.



This report has studied every segment and provided the market size using historical data. They have also talked about the growth opportunities that the segment may pose in the future. This study bestows production and revenue data by type, and during the historical period (2018-2023) and forecast period (2024-2029).

Sputtering Target for Semiconductor segment by Type

Metal Target

Alloy Target

Ceramic Compound Target

Application Insights

This report has provided the market size (production and revenue data) by application, during the historical period (2018-2023) and forecast period (2024-2029).

This report also outlines the market trends of each segment and consumer behaviors impacting the Sputtering Target for Semiconductor market and what implications these may have on the industry's future. This report can help to understand the relevant market and consumer trends that are driving the Sputtering Target for Semiconductor market.

Sputtering Target for Semiconductor segment by Application

Consumer Electronics

Vehicle Electronics

Communication Electronics

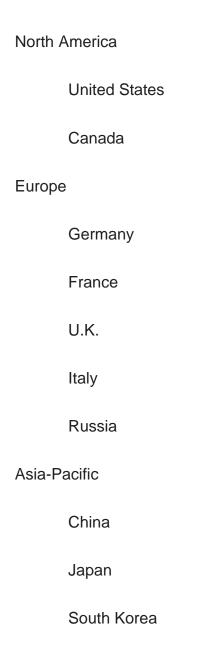
Others

Regional Outlook



This section of the report provides key insights regarding various regions and the key players operating in each region. Economic, social, environmental, technological, and political factors have been taken into consideration while assessing the growth of the particular region/country. The readers will also get their hands on the revenue and sales data of each region and country for the period 2018-2029.

The market has been segmented into various major geographies, including North America, Europe, Asia-Pacific, South America. Detailed analysis of major countries such as the USA, Germany, the U.K., Italy, France, China, Japan, South Korea, Southeast Asia, and India will be covered within the regional segment. For market estimates, data are going to be provided for 2022 because of the base year, with estimates for 2023 and forecast value for 2029.





	India
	Australia
	China Taiwan
	Indonesia
	Thailand
	Malaysia
Latin A	America
	Mexico
	Brazil
	Argentina
Drivers &	Barriers

Key Drivers & Barriers

High-impact rendering factors and drivers have been studied in this report to aid the readers to understand the general development. Moreover, the report includes restraints and challenges that may act as stumbling blocks on the way of the players. This will assist the users to be attentive and make informed decisions related to business. Specialists have also laid their focus on the upcoming business prospects.

COVID-19 and Russia-Ukraine War Influence Analysis

The readers in the section will understand how the Sputtering Target for Semiconductor market scenario changed across the globe during the pandemic, post-pandemic and Russia-Ukraine War. The study is done keeping in view the changes in aspects such as demand, consumption, transportation, consumer behavior, supply chain management, export and import, and production. The industry experts have also highlighted the key factors that will help create opportunities for players and stabilize the overall industry in the years to come.



Reasons to Buy This Report

This report will help the readers to understand the competition within the industries and strategies for the competitive environment to enhance the potential profit. The report also focuses on the competitive landscape of the global Sputtering Target for Semiconductor market, and introduces in detail the market share, industry ranking, competitor ecosystem, market performance, new product development, operation situation, expansion, and acquisition. etc. of the main players, which helps the readers to identify the main competitors and deeply understand the competition pattern of the market.

This report will help stakeholders to understand the global industry status and trends of Sputtering Target for Semiconductor and provides them with information on key market drivers, restraints, challenges, and opportunities.

This report will help stakeholders to understand competitors better and gain more insights to strengthen their position in their businesses. The competitive landscape section includes the market share and rank (in volume and value), competitor ecosystem, new product development, expansion, and acquisition.

This report stays updated with novel technology integration, features, and the latest developments in the market

This report helps stakeholders to understand the COVID-19 and Russia-Ukraine War Influence on the Sputtering Target for Semiconductor industry.

This report helps stakeholders to gain insights into which regions to target globally

This report helps stakeholders to gain insights into the end-user perception concerning the adoption of Sputtering Target for Semiconductor.

This report helps stakeholders to identify some of the key players in the market and understand their valuable contribution.

Core Chapters

Chapter 1: Research objectives, research methods, data sources, data cross-validation;

Chapter 2: Introduces the report scope of the report, executive summary of different



market segments (by region, product type, application, etc), including the market size of each market segment, future development potential, and so on. It offers a high-level view of the current state of the market and its likely evolution in the short to mid-term, and long term.

Chapter 3: Detailed analysis of Sputtering Target for Semiconductor manufacturers competitive landscape, price, production and value market share, latest development plan, merger, and acquisition information, etc.

Chapter 4: Provides profiles of key players, introducing the basic situation of the main companies in the market in detail, including product production/output, value, price, gross margin, product introduction, recent development, etc.

Chapter 5: Production/output, value of Sputtering Target for Semiconductor by region/country. It provides a quantitative analysis of the market size and development potential of each region in the next six years.

Chapter 6: Consumption of Sputtering Target for Semiconductor in regional level and country level. It provides a quantitative analysis of the market size and development potential of each region and its main countries and introduces the market development, future development prospects, market space, and production of each country in the world.

Chapter 7: Provides the analysis of various market segments by type, covering the market size and development potential of each market segment, to help readers find the blue ocean market in different market segments.

Chapter 8: Provides the analysis of various market segments by application, covering the market size and development potential of each market segment, to help readers find the blue ocean market in different downstream markets.

Chapter 9: Analysis of industrial chain, including the upstream and downstream of the industry.

Chapter 10: Introduces the market dynamics, latest developments of the market, the driving factors and restrictive factors of the market, the challenges and risks faced by manufacturers in the industry, and the analysis of relevant policies in the industry.

Chapter 11: The main points and conclusions of the report.



Contents

1 PREFACE

- 1.1 Scope of Report
- 1.2 Reasons for Doing This Study
- 1.3 Research Methodology
- 1.4 Research Process
- 1.5 Data Source
 - 1.5.1 Secondary Sources
 - 1.5.2 Primary Sources

2 MARKET OVERVIEW

- 2.1 Product Definition
- 2.2 Sputtering Target for Semiconductor by Type
 - 2.2.1 Market Value Comparison by Type (2018 VS 2022 VS 2029) & (US\$ Million)
 - 1.2.2 Metal Target
 - 1.2.3 Alloy Target
- 1.2.4 Ceramic Compound Target
- 2.3 Sputtering Target for Semiconductor by Application
- 2.3.1 Market Value Comparison by Application (2018 VS 2022 VS 2029) & (US\$ Million)
 - 2.3.2 Consumer Electronics
 - 2.3.3 Vehicle Electronics
 - 2.3.4 Communication Electronics
 - 2.3.5 Others
- 2.4 Global Market Growth Prospects
- 2.4.1 Global Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 2.4.2 Global Sputtering Target for Semiconductor Production Capacity Estimates and Forecasts (2018-2029)
- 2.4.3 Global Sputtering Target for Semiconductor Production Estimates and Forecasts (2018-2029)
- 2.4.4 Global Sputtering Target for Semiconductor Market Average Price (2018-2029)

3 MARKET COMPETITIVE LANDSCAPE BY MANUFACTURERS

3.1 Global Sputtering Target for Semiconductor Production by Manufacturers



(2018-2023)

- 3.2 Global Sputtering Target for Semiconductor Production Value by Manufacturers (2018-2023)
- 3.3 Global Sputtering Target for Semiconductor Average Price by Manufacturers (2018-2023)
- 3.4 Global Sputtering Target for Semiconductor Industry Manufacturers Ranking, 2021 VS 2022 VS 2023
- 3.5 Global Sputtering Target for Semiconductor Key Manufacturers, Manufacturing Sites & Headquarters
- 3.6 Global Sputtering Target for Semiconductor Manufacturers, Product Type & Application
- 3.7 Global Sputtering Target for Semiconductor Manufacturers, Date of Enter into This Industry
- 3.8 Global Sputtering Target for Semiconductor Market CR5 and HHI
- 3.9 Global Manufacturers Mergers & Acquisition

4 MANUFACTURERS PROFILED

- 4.1 Materion (Heraeus)
 - 4.1.1 Materion (Heraeus) Sputtering Target for Semiconductor Company Information
 - 4.1.2 Materion (Heraeus) Sputtering Target for Semiconductor Business Overview
- 4.1.3 Materion (Heraeus) Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.1.4 Materion (Heraeus) Product Portfolio
 - 4.1.5 Materion (Heraeus) Recent Developments
- 4.2 JX Nippon Mining & Metals Corporation
- 4.2.1 JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Company Information
- 4.2.2 JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Business Overview
- 4.2.3 JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
- 4.2.4 JX Nippon Mining & Metals Corporation Product Portfolio
- 4.2.5 JX Nippon Mining & Metals Corporation Recent Developments
- 4.3 Praxair
 - 4.3.1 Praxair Sputtering Target for Semiconductor Company Information
 - 4.3.2 Praxair Sputtering Target for Semiconductor Business Overview
- 4.3.3 Praxair Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)



- 4.3.4 Praxair Product Portfolio
- 4.3.5 Praxair Recent Developments
- 4.4 Plansee SE
 - 4.4.1 Plansee SE Sputtering Target for Semiconductor Company Information
 - 4.4.2 Plansee SE Sputtering Target for Semiconductor Business Overview
- 4.4.3 Plansee SE Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.4.4 Plansee SE Product Portfolio
 - 4.4.5 Plansee SE Recent Developments
- 4.5 Hitachi Metals
- 4.5.1 Hitachi Metals Sputtering Target for Semiconductor Company Information
- 4.5.2 Hitachi Metals Sputtering Target for Semiconductor Business Overview
- 4.5.3 Hitachi Metals Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.5.4 Hitachi Metals Product Portfolio
 - 4.5.5 Hitachi Metals Recent Developments
- 4.6 Honeywell
 - 4.6.1 Honeywell Sputtering Target for Semiconductor Company Information
 - 4.6.2 Honeywell Sputtering Target for Semiconductor Business Overview
- 4.6.3 Honeywell Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.6.4 Honeywell Product Portfolio
 - 4.6.5 Honeywell Recent Developments
- 4.7 TOSOH
 - 4.7.1 TOSOH Sputtering Target for Semiconductor Company Information
 - 4.7.2 TOSOH Sputtering Target for Semiconductor Business Overview
- 4.7.3 TOSOH Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.7.4 TOSOH Product Portfolio
 - 4.7.5 TOSOH Recent Developments
- 4.8 Sumitomo Chemical
 - 4.8.1 Sumitomo Chemical Sputtering Target for Semiconductor Company Information
 - 4.8.2 Sumitomo Chemical Sputtering Target for Semiconductor Business Overview
- 4.8.3 Sumitomo Chemical Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.8.4 Sumitomo Chemical Product Portfolio
 - 4.8.5 Sumitomo Chemical Recent Developments
- 4.9 ULVAC
 - 4.9.1 ULVAC Sputtering Target for Semiconductor Company Information



- 4.9.2 ULVAC Sputtering Target for Semiconductor Business Overview
- 4.9.3 ULVAC Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.9.4 ULVAC Product Portfolio
 - 4.9.5 ULVAC Recent Developments
- 4.10 Ningbo Jiangfeng
- 4.10.1 Ningbo Jiangfeng Sputtering Target for Semiconductor Company Information
- 4.10.2 Ningbo Jiangfeng Sputtering Target for Semiconductor Business Overview
- 4.10.3 Ningbo Jiangfeng Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 4.10.4 Ningbo Jiangfeng Product Portfolio
 - 4.10.5 Ningbo Jiangfeng Recent Developments
- 7.11 Luvata
 - 7.11.1 Luvata Sputtering Target for Semiconductor Company Information
 - 7.11.2 Luvata Sputtering Target for Semiconductor Business Overview
- 4.11.3 Luvata Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.11.4 Luvata Product Portfolio
 - 7.11.5 Luvata Recent Developments
- 7.12 GRIKIN Advanced Material
- 7.12.1 GRIKIN Advanced Material Sputtering Target for Semiconductor Company Information
- 7.12.2 GRIKIN Advanced Material Sputtering Target for Semiconductor Business Overview
- 7.12.3 GRIKIN Advanced Material Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.12.4 GRIKIN Advanced Material Product Portfolio
 - 7.12.5 GRIKIN Advanced Material Recent Developments
- 7.13 Luoyang Sifon Electronic Materials
- 7.13.1 Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Company Information
- 7.13.2 Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Business Overview
- 7.13.3 Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.13.4 Luoyang Sifon Electronic Materials Product Portfolio
 - 7.13.5 Luoyang Sifon Electronic Materials Recent Developments
- 7.14 FURAYA Metals
- 7.14.1 FURAYA Metals Sputtering Target for Semiconductor Company Information



- 7.14.2 FURAYA Metals Sputtering Target for Semiconductor Business Overview
- 7.14.3 FURAYA Metals Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.14.4 FURAYA Metals Product Portfolio
 - 7.14.5 FURAYA Metals Recent Developments
- 7.15 Advantec
 - 7.15.1 Advantec Sputtering Target for Semiconductor Company Information
 - 7.15.2 Advantec Sputtering Target for Semiconductor Business Overview
- 7.15.3 Advantec Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.15.4 Advantec Product Portfolio
 - 7.15.5 Advantec Recent Developments
- 7.16 Fujian Acetron New Materials Co., Ltd
- 7.16.1 Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Company Information
- 7.16.2 Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Business Overview
- 7.16.3 Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
- 7.16.4 Fujian Acetron New Materials Co., Ltd Product Portfolio
- 7.16.5 Fujian Acetron New Materials Co., Ltd Recent Developments
- 7.17 Umicore Thin Film Products
- 7.17.1 Umicore Thin Film Products Sputtering Target for Semiconductor Company Information
- 7.17.2 Umicore Thin Film Products Sputtering Target for Semiconductor Business Overview
- 7.17.3 Umicore Thin Film Products Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.17.4 Umicore Thin Film Products Product Portfolio
 - 7.17.5 Umicore Thin Film Products Recent Developments
- 7.18 Angstrom Sciences
 - 7.18.1 Angstrom Sciences Sputtering Target for Semiconductor Company Information
 - 7.18.2 Angstrom Sciences Sputtering Target for Semiconductor Business Overview
- 7.18.3 Angstrom Sciences Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.18.4 Angstrom Sciences Product Portfolio
 - 7.18.5 Angstrom Sciences Recent Developments
- 7.19 Changzhou Sujing Electronic Material
- 7.19.1 Changzhou Sujing Electronic Material Sputtering Target for Semiconductor



Company Information

- 7.19.2 Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Business Overview
- 7.19.3 Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Production, Value and Gross Margin (2018-2023)
 - 7.19.4 Changzhou Sujing Electronic Material Product Portfolio
 - 7.19.5 Changzhou Sujing Electronic Material Recent Developments

5 GLOBAL SPUTTERING TARGET FOR SEMICONDUCTOR PRODUCTION BY REGION

- 5.1 Global Sputtering Target for Semiconductor Production Estimates and Forecasts by Region: 2018 VS 2022 VS 2029
- 5.2 Global Sputtering Target for Semiconductor Production by Region: 2018-2029
 - 5.2.1 Global Sputtering Target for Semiconductor Production by Region: 2018-2023
- 5.2.2 Global Sputtering Target for Semiconductor Production Forecast by Region (2024-2029)
- 5.3 Global Sputtering Target for Semiconductor Production Value Estimates and Forecasts by Region: 2018 VS 2022 VS 2029
- 5.4 Global Sputtering Target for Semiconductor Production Value by Region: 2018-2029
- 5.4.1 Global Sputtering Target for Semiconductor Production Value by Region: 2018-2023
- 5.4.2 Global Sputtering Target for Semiconductor Production Value Forecast by Region (2024-2029)
- 5.5 Global Sputtering Target for Semiconductor Market Price Analysis by Region (2018-2023)
- 5.6 Global Sputtering Target for Semiconductor Production and Value, YOY Growth
- 5.6.1 North America Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 5.6.2 Europe Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 5.6.3 China Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 5.6.4 Japan Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 5.6.5 South Korea Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2018-2029)

6 GLOBAL SPUTTERING TARGET FOR SEMICONDUCTOR CONSUMPTION BY



REGION

- 6.1 Global Sputtering Target for Semiconductor Consumption Estimates and Forecasts by Region: 2018 VS 2022 VS 2029
- 6.2 Global Sputtering Target for Semiconductor Consumption by Region (2018-2029)
 - 6.2.1 Global Sputtering Target for Semiconductor Consumption by Region: 2018-2029
- 6.2.2 Global Sputtering Target for Semiconductor Forecasted Consumption by Region (2024-2029)
- 6.3 North America
- 6.3.1 North America Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029
- 6.3.2 North America Sputtering Target for Semiconductor Consumption by Country (2018-2029)
 - 6.3.3 United States
 - 6.3.4 Canada
- 6.4 Europe
- 6.4.1 Europe Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029
- 6.4.2 Europe Sputtering Target for Semiconductor Consumption by Country (2018-2029)
 - 6.4.3 Germany
 - 6.4.4 France
 - 6.4.5 U.K.
- 6.4.6 Italy
- 6.4.7 Russia
- 6.5 Asia Pacific
- 6.5.1 Asia Pacific Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029
- 6.5.2 Asia Pacific Sputtering Target for Semiconductor Consumption by Country (2018-2029)
 - 6.5.3 China
 - 6.5.4 Japan
 - 6.5.5 South Korea
 - 6.5.6 China Taiwan
 - 6.5.7 Southeast Asia
 - 6.5.8 India
 - 6.5.9 Australia
- 6.6 Latin America, Middle East & Africa
 - 6.6.1 Latin America, Middle East & Africa Sputtering Target for Semiconductor



Consumption Growth Rate by Country: 2018 VS 2022 VS 2029

6.6.2 Latin America, Middle East & Africa Sputtering Target for Semiconductor Consumption by Country (2018-2029)

- 6.6.3 Mexico
- 6.6.4 Brazil
- 6.6.5 Turkey
- 6.6.5 GCC Countries

7 SEGMENT BY TYPE

- 7.1 Global Sputtering Target for Semiconductor Production by Type (2018-2029)
- 7.1.1 Global Sputtering Target for Semiconductor Production by Type (2018-2029) & (Tons)
- 7.1.2 Global Sputtering Target for Semiconductor Production Market Share by Type (2018-2029)
- 7.2 Global Sputtering Target for Semiconductor Production Value by Type (2018-2029)
- 7.2.1 Global Sputtering Target for Semiconductor Production Value by Type (2018-2029) & (US\$ Million)
- 7.2.2 Global Sputtering Target for Semiconductor Production Value Market Share by Type (2018-2029)
- 7.3 Global Sputtering Target for Semiconductor Price by Type (2018-2029)

8 SEGMENT BY APPLICATION

- 8.1 Global Sputtering Target for Semiconductor Production by Application (2018-2029)
- 8.1.1 Global Sputtering Target for Semiconductor Production by Application (2018-2029) & (Tons)
- 8.1.2 Global Sputtering Target for Semiconductor Production by Application (2018-2029) & (Tons)
- 8.2 Global Sputtering Target for Semiconductor Production Value by Application (2018-2029)
- 8.2.1 Global Sputtering Target for Semiconductor Production Value by Application (2018-2029) & (US\$ Million)
- 8.2.2 Global Sputtering Target for Semiconductor Production Value Market Share by Application (2018-2029)
- 8.3 Global Sputtering Target for Semiconductor Price by Application (2018-2029)

9 VALUE CHAIN AND SALES CHANNELS ANALYSIS OF THE MARKET



- 9.1 Sputtering Target for Semiconductor Value Chain Analysis
 - 9.1.1 Sputtering Target for Semiconductor Key Raw Materials
 - 9.1.2 Raw Materials Key Suppliers
 - 9.1.3 Sputtering Target for Semiconductor Production Mode & Process
- 9.2 Sputtering Target for Semiconductor Sales Channels Analysis
 - 9.2.1 Direct Comparison with Distribution Share
 - 9.2.2 Sputtering Target for Semiconductor Distributors
 - 9.2.3 Sputtering Target for Semiconductor Customers

10 GLOBAL SPUTTERING TARGET FOR SEMICONDUCTOR ANALYZING MARKET DYNAMICS

- 10.1 Sputtering Target for Semiconductor Industry Trends
- 10.2 Sputtering Target for Semiconductor Industry Drivers
- 10.3 Sputtering Target for Semiconductor Industry Opportunities and Challenges
- 10.4 Sputtering Target for Semiconductor Industry Restraints

11 REPORT CONCLUSION

12 DISCLAIMER



List Of Tables

LIST OF TABLES

- Table 1. Secondary Sources
- Table 2. Primary Sources
- Table 3. Market Value Comparison by Type (2018 VS 2022 VS 2029) & (US\$ Million)
- Table 4. Market Value Comparison by Application (2018 VS 2022 VS 2029) & (US\$ Million)
- Table 5. Global Sputtering Target for Semiconductor Production by Manufacturers (Tons) & (2018-2023)
- Table 6. Global Sputtering Target for Semiconductor Production Market Share by Manufacturers
- Table 7. Global Sputtering Target for Semiconductor Production Value by Manufacturers (US\$ Million) & (2018-2023)
- Table 8. Global Sputtering Target for Semiconductor Production Value Market Share by Manufacturers (2018-2023)
- Table 9. Global Sputtering Target for Semiconductor Average Price (US\$/Kg) of Key Manufacturers (2018-2023)
- Table 10. Global Sputtering Target for Semiconductor Industry Manufacturers Ranking, 2021 VS 2022 VS 2023
- Table 11. Global Sputtering Target for Semiconductor Manufacturers, Product Type & Application
- Table 12. Global Manufacturers Market Concentration Ratio (CR5 and HHI)
- Table 13. Global Sputtering Target for Semiconductor by Manufacturers Type (Tier 1,
- Tier 2, and Tier 3) & (based on the Production Value of 2022)
- Table 14. Manufacturers Mergers & Acquisitions, Expansion Plans)
- Table 15. Materion (Heraeus) Sputtering Target for Semiconductor Company Information
- Table 16. Materion (Heraeus) Business Overview
- Table 17. Materion (Heraeus) Sputtering Target for Semiconductor Production (Tons),
- Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 18. Materion (Heraeus) Product Portfolio
- Table 19. Materion (Heraeus) Recent Developments
- Table 20. JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Company Information
- Table 21. JX Nippon Mining & Metals Corporation Business Overview
- Table 22. JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)



- Table 23. JX Nippon Mining & Metals Corporation Product Portfolio
- Table 24. JX Nippon Mining & Metals Corporation Recent Developments
- Table 25. Praxair Sputtering Target for Semiconductor Company Information
- Table 26. Praxair Business Overview
- Table 27. Praxair Sputtering Target for Semiconductor Production (Tons), Value (US\$
- Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 28. Praxair Product Portfolio
- Table 29. Praxair Recent Developments
- Table 30. Plansee SE Sputtering Target for Semiconductor Company Information
- Table 31. Plansee SE Business Overview
- Table 32. Plansee SE Sputtering Target for Semiconductor Production (Tons), Value
- (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 33. Plansee SE Product Portfolio
- Table 34. Plansee SE Recent Developments
- Table 35. Hitachi Metals Sputtering Target for Semiconductor Company Information
- Table 36. Hitachi Metals Business Overview
- Table 37. Hitachi Metals Sputtering Target for Semiconductor Production (Tons), Value
- (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 38. Hitachi Metals Product Portfolio
- Table 39. Hitachi Metals Recent Developments
- Table 40. Honeywell Sputtering Target for Semiconductor Company Information
- Table 41. Honeywell Business Overview
- Table 42. Honeywell Sputtering Target for Semiconductor Production (Tons), Value
- (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 43. Honeywell Product Portfolio
- Table 44. Honeywell Recent Developments
- Table 45. TOSOH Sputtering Target for Semiconductor Company Information
- Table 46. TOSOH Business Overview
- Table 47. TOSOH Sputtering Target for Semiconductor Production (Tons), Value (US\$
- Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 48. TOSOH Product Portfolio
- Table 49. TOSOH Recent Developments
- Table 50. Sumitomo Chemical Sputtering Target for Semiconductor Company
- Information
- Table 51. Sumitomo Chemical Business Overview
- Table 52. Sumitomo Chemical Sputtering Target for Semiconductor Production (Tons),
- Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)
- Table 53. Sumitomo Chemical Product Portfolio
- Table 54. Sumitomo Chemical Recent Developments



Table 55. ULVAC Sputtering Target for Semiconductor Company Information

Table 56. ULVAC Business Overview

Table 57. ULVAC Sputtering Target for Semiconductor Production (Tons), Value (US\$

Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 58. ULVAC Product Portfolio

Table 59. ULVAC Recent Developments

Table 60. Ningbo Jiangfeng Sputtering Target for Semiconductor Company Information

Table 61. Ningbo Jiangfeng Business Overview

Table 62. Ningbo Jiangfeng Sputtering Target for Semiconductor Production (Tons),

Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 63. Ningbo Jiangfeng Product Portfolio

Table 64. Ningbo Jiangfeng Recent Developments

Table 65. Luvata Sputtering Target for Semiconductor Company Information

Table 66. Luvata Business Overview

Table 67. Luvata Sputtering Target for Semiconductor Production (Tons), Value (US\$

Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 68. Luvata Product Portfolio

Table 69. Luvata Recent Developments

Table 70. GRIKIN Advanced Material Sputtering Target for Semiconductor Company Information

Table 71. GRIKIN Advanced Material Business Overview

Table 72. GRIKIN Advanced Material Sputtering Target for Semiconductor Production

(Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 73. GRIKIN Advanced Material Product Portfolio

Table 74. GRIKIN Advanced Material Recent Developments

Table 75. Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor

Company Information

Table 76. Luoyang Sifon Electronic Materials Business Overview

Table 77. Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor

Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 78. Luoyang Sifon Electronic Materials Product Portfolio

Table 79. Luoyang Sifon Electronic Materials Recent Developments

Table 80. FURAYA Metals Sputtering Target for Semiconductor Company Information

Table 81. FURAYA Metals Business Overview

Table 82. FURAYA Metals Sputtering Target for Semiconductor Production (Tons),

Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 83. FURAYA Metals Product Portfolio

Table 84. FURAYA Metals Recent Developments

Table 85. FURAYA Metals Sputtering Target for Semiconductor Company Information



Table 86. Advantec Business Overview

Table 87. Advantec Sputtering Target for Semiconductor Production (Tons), Value (US\$

Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 88. Advantec Product Portfolio

Table 89. Advantec Recent Developments

Table 90. Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Company Information

Table 91. Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor

Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 92. Fujian Acetron New Materials Co., Ltd Product Portfolio

Table 93. Fujian Acetron New Materials Co., Ltd Recent Developments

Table 94. Umicore Thin Film Products Sputtering Target for Semiconductor Company Information

Table 95. Umicore Thin Film Products Business Overview

Table 96. Umicore Thin Film Products Sputtering Target for Semiconductor Production

(Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 97. Umicore Thin Film Products Product Portfolio

Table 98. Umicore Thin Film Products Recent Developments

Table 99. Angstrom Sciences Sputtering Target for Semiconductor Company Information

Table 100. Angstrom Sciences Business Overview

Table 101. Angstrom Sciences Sputtering Target for Semiconductor Production (Tons),

Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 102. Angstrom Sciences Product Portfolio

Table 103. Angstrom Sciences Recent Developments

Table 104. Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Company Information

Table 105. Changzhou Sujing Electronic Material Business Overview

Table 106. Changzhou Sujing Electronic Material Sputtering Target for Semiconductor

Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2018-2023)

Table 107. Changzhou Sujing Electronic Material Product Portfolio

Table 108. Changzhou Sujing Electronic Material Recent Developments

Table 109. Global Sputtering Target for Semiconductor Production Comparison by

Region: 2018 VS 2022 VS 2029 (Tons)

Table 110. Global Sputtering Target for Semiconductor Production by Region (2018-2023) & (Tons)

Table 111. Global Sputtering Target for Semiconductor Production Market Share by Region (2018-2023)

Table 112. Global Sputtering Target for Semiconductor Production Forecast by Region



(2024-2029) & (Tons)

Table 113. Global Sputtering Target for Semiconductor Production Market Share Forecast by Region (2024-2029)

Table 114. Global Sputtering Target for Semiconductor Production Value Comparison by Region: 2018 VS 2022 VS 2029 (US\$ Million)

Table 115. Global Sputtering Target for Semiconductor Production Value by Region (2018-2023) & (US\$ Million)

Table 116. Global Sputtering Target for Semiconductor Production Value Market Share by Region (2018-2023)

Table 117. Global Sputtering Target for Semiconductor Production Value Forecast by Region (2024-2029) & (US\$ Million)

Table 118. Global Sputtering Target for Semiconductor Production Value Market Share Forecast by Region (2024-2029)

Table 119. Global Sputtering Target for Semiconductor Market Average Price (US\$/Kg) by Region (2018-2023)

Table 120. Global Sputtering Target for Semiconductor Consumption Comparison by Region: 2018 VS 2022 VS 2029 (Tons)

Table 121. Global Sputtering Target for Semiconductor Consumption by Region (2018-2023) & (Tons)

Table 122. Global Sputtering Target for Semiconductor Consumption Market Share by Region (2018-2023)

Table 123. Global Sputtering Target for Semiconductor Forecasted Consumption by Region (2024-2029) & (Tons)

Table 124. Global Sputtering Target for Semiconductor Forecasted Consumption Market Share by Region (2024-2029)

Table 125. North America Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (Tons)

Table 126. North America Sputtering Target for Semiconductor Consumption by Country (2018-2023) & (Tons)

Table 127. North America Sputtering Target for Semiconductor Consumption by Country (2024-2029) & (Tons)

Table 128. Europe Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (Tons)

Table 129. Europe Sputtering Target for Semiconductor Consumption by Country (2018-2023) & (Tons)

Table 130. Europe Sputtering Target for Semiconductor Consumption by Country (2024-2029) & (Tons)

Table 131. Asia Pacific Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (Tons)



Table 132. Asia Pacific Sputtering Target for Semiconductor Consumption by Country (2018-2023) & (Tons)

Table 133. Asia Pacific Sputtering Target for Semiconductor Consumption by Country (2024-2029) & (Tons)

Table 134. Latin America, Middle East & Africa Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (Tons)

Table 135. Latin America, Middle East & Africa Sputtering Target for Semiconductor Consumption by Country (2018-2023) & (Tons)

Table 136. Latin America, Middle East & Africa Sputtering Target for Semiconductor Consumption by Country (2024-2029) & (Tons)

Table 137. Global Sputtering Target for Semiconductor Production by Type (2018-2023) & (Tons)

Table 138. Global Sputtering Target for Semiconductor Production by Type (2024-2029) & (Tons)

Table 139. Global Sputtering Target for Semiconductor Production Market Share by Type (2018-2023)

Table 140. Global Sputtering Target for Semiconductor Production Market Share by Type (2024-2029)

Table 141. Global Sputtering Target for Semiconductor Production Value by Type (2018-2023) & (US\$ Million)

Table 142. Global Sputtering Target for Semiconductor Production Value by Type (2024-2029) & (US\$ Million)

Table 143. Global Sputtering Target for Semiconductor Production Value Market Share by Type (2018-2023)

Table 144. Global Sputtering Target for Semiconductor Production Value Market Share by Type (2024-2029)

Table 145. Global Sputtering Target for Semiconductor Price by Type (2018-2023) & (US\$/Kg)

Table 146. Global Sputtering Target for Semiconductor Price by Type (2024-2029) & (US\$/Kg)

Table 147. Global Sputtering Target for Semiconductor Production by Application (2018-2023) & (Tons)

Table 148. Global Sputtering Target for Semiconductor Production by Application (2024-2029) & (Tons)

Table 149. Global Sputtering Target for Semiconductor Production Market Share by Application (2018-2023)

Table 150. Global Sputtering Target for Semiconductor Production Market Share by Application (2024-2029)

Table 151. Global Sputtering Target for Semiconductor Production Value by Application



(2018-2023) & (US\$ Million)

Table 152. Global Sputtering Target for Semiconductor Production Value by Application (2024-2029) & (US\$ Million)

Table 153. Global Sputtering Target for Semiconductor Production Value Market Share by Application (2018-2023)

Table 154. Global Sputtering Target for Semiconductor Production Value Market Share by Application (2024-2029)

Table 155. Global Sputtering Target for Semiconductor Price by Application (2018-2023) & (US\$/Kg)

Table 156. Global Sputtering Target for Semiconductor Price by Application (2024-2029) & (US\$/Kg)

Table 157. Key Raw Materials

Table 158. Raw Materials Key Suppliers

Table 159. Sputtering Target for Semiconductor Distributors List

Table 160. Sputtering Target for Semiconductor Customers List

Table 161. Sputtering Target for Semiconductor Industry Trends

Table 162. Sputtering Target for Semiconductor Industry Drivers

Table 163. Sputtering Target for Semiconductor Industry Restraints

Table 164. Authors List of This Report



List Of Figures

LIST OF FIGURES

- Figure 1. Research Methodology
- Figure 2. Research Process
- Figure 3. Key Executives Interviewed
- Figure 4. Sputtering Target for SemiconductorProduct Picture
- Figure 5. Market Value Comparison by Type (2018 VS 2022 VS 2029) & (US\$ Million)
- Figure 6. Metal Target Product Picture
- Figure 7. Alloy Target Product Picture
- Figure 8. Ceramic Compound Target Product Picture
- Figure 9. Consumer Electronics Product Picture
- Figure 10. Vehicle Electronics Product Picture
- Figure 11. Communication Electronics Product Picture
- Figure 12. Others Product Picture
- Figure 13. Global Sputtering Target for Semiconductor Production Value (US\$ Million),

2018 VS 2022 VS 2029

- Figure 14. Global Sputtering Target for Semiconductor Production Value (2018-2029) & (US\$ Million)
- Figure 15. Global Sputtering Target for Semiconductor Production Capacity (2018-2029) & (Tons)
- Figure 16. Global Sputtering Target for Semiconductor Production (2018-2029) & (Tons)
- Figure 17. Global Sputtering Target for Semiconductor Average Price (US\$/Kg) & (2018-2029)
- Figure 18. Global Sputtering Target for Semiconductor Key Manufacturers,

Manufacturing Sites & Headquarters

- Figure 19. Global Sputtering Target for Semiconductor Manufacturers, Date of Enter into This Industry
- Figure 20. Global Top 5 and 10 Sputtering Target for Semiconductor Players Market Share by Production Valu in 2022
- Figure 21. Manufacturers Type (Tier 1, Tier 2, and Tier 3): 2018 VS 2022
- Figure 22. Global Sputtering Target for Semiconductor Production Comparison by
- Region: 2018 VS 2022 VS 2029 (Tons)
- Figure 23. Global Sputtering Target for Semiconductor Production Market Share by

Region: 2018 VS 2022 VS 2029

- Figure 24. Global Sputtering Target for Semiconductor Production Value Comparison by
- Region: 2018 VS 2022 VS 2029 (US\$ Million)
- Figure 25. Global Sputtering Target for Semiconductor Production Value Market Share



by Region: 2018 VS 2022 VS 2029

Figure 26. North America Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)

Figure 27. Europe Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)

Figure 28. China Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)

Figure 29. Japan Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)

Figure 30. South Korea Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)

Figure 31. Global Sputtering Target for Semiconductor Consumption Comparison by Region: 2018 VS 2022 VS 2029 (Tons)

Figure 32. Global Sputtering Target for Semiconductor Consumption Market Share by Region: 2018 VS 2022 VS 2029

Figure 33. North America Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 34. North America Sputtering Target for Semiconductor Consumption Market Share by Country (2018-2029)

Figure 35. United States Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 36. Canada Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 37. Europe Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 38. Europe Sputtering Target for Semiconductor Consumption Market Share by Country (2018-2029)

Figure 39. Germany Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 40. France Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 41. U.K. Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 42. Italy Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 43. Netherlands Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 44. Asia Pacific Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)



Figure 45. Asia Pacific Sputtering Target for Semiconductor Consumption Market Share by Country (2018-2029)

Figure 46. China Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 47. Japan Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 48. South Korea Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 49. China Taiwan Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 50. Southeast Asia Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 51. India Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 52. Australia Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 53. Latin America, Middle East & Africa Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 54. Latin America, Middle East & Africa Sputtering Target for Semiconductor Consumption Market Share by Country (2018-2029)

Figure 55. Mexico Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 56. Brazil Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 57. Turkey Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 58. GCC Countries Sputtering Target for Semiconductor Consumption and Growth Rate (2018-2029) & (Tons)

Figure 59. Global Sputtering Target for Semiconductor Production Market Share by Type (2018-2029)

Figure 60. Global Sputtering Target for Semiconductor Production Value Market Share by Type (2018-2029)

Figure 61. Global Sputtering Target for Semiconductor Price (US\$/Kg) by Type (2018-2029)

Figure 62. Global Sputtering Target for Semiconductor Production Market Share by Application (2018-2029)

Figure 63. Global Sputtering Target for Semiconductor Production Value Market Share by Application (2018-2029)

Figure 64. Global Sputtering Target for Semiconductor Price (US\$/Kg) by Application



(2018-2029)

- Figure 65. Sputtering Target for Semiconductor Value Chain
- Figure 66. Sputtering Target for Semiconductor Production Mode & Process
- Figure 67. Direct Comparison with Distribution Share
- Figure 68. Distributors Profiles
- Figure 69. Sputtering Target for Semiconductor Industry Opportunities and Challenges



I would like to order

Product name: Sputtering Target for Semiconductor Industry Research Report 2023

Product link: https://marketpublishers.com/r/S64EC3E21BCCEN.html

Price: US\$ 2,950.00 (Single User License / Electronic Delivery)

If you want to order Corporate License or Hard Copy, please, contact our Customer

Service:

info@marketpublishers.com

Payment

To pay by Credit Card (Visa, MasterCard, American Express, PayPal), please, click button on product page https://marketpublishers.com/r/S64EC3E21BCCEN.html

To pay by Wire Transfer, please, fill in your contact details in the form below:

First name:	
Last name:	
Email:	
Company:	
Address:	
City:	
Zip code:	
Country:	
Tel:	
Fax:	
Your message:	
	**All fields are required
	Custumer signature

Please, note that by ordering from marketpublishers.com you are agreeing to our Terms & Conditions at https://marketpublishers.com/docs/terms.html

To place an order via fax simply print this form, fill in the information below and fax the completed form to +44 20 7900 3970